AMENDMENTS TO THE CLAIMS

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Please amend the claims as follows.

1. (Original) An antistatic agent for resins, containing phosphonium salts represented by the general formula (1):

$$R^{1}$$
 $R^{2} - P^{+} - R^{4} X^{-} \cdots (1)$
 R^{3}

(wherein R¹, R², and R³ are each a straight-chain or branched alkyl group having 3 to 8 carbon atoms, and R⁴ is a straight-chain or branched alkyl group having 10 to 22 carbon atoms; each alkyl group may have substituted hydroxy group or alkoxy group; R¹, R², and R³ may be the same or different from each another; and X⁻ is a tetrafluoroborate ion or a hexafluorophosphate ion).

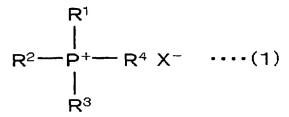
- 2. (Original) The antistatic agent for resins according to Claim 1, wherein the phosphonium salt is tri-n-butyl-n-hexadecylphosphonium tetrafluoroborate.
- 3. (Original) The antistatic agent for resins according to Claim 1, wherein the phosphonium salt is tri-n-butyl-n-hexadecylphosphonium hexafluorophosphate.
- (Currently Amended) The antistatic agent for resins according to any of Claims 1 to 3 Claim
 wherein the residual halogen is 500 ppm or less.
- 5. (Currently Amended) The antistatic agent for resins according to any of Claims 1 to 3

 Claim 1, wherein the antistatic agent is for thermoplastic resins.
- 6. (Original) The antistatic agent for resins according to Claim 5, wherein the antistatic agent is for polyamide resins or for polyester resins.
- 7. (Curently Amended) The antistatic agent for resins according to any of Claims 1 to 4 Claim 1, wherein the antistatic agent is for thermoset resins.

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8. (Original) The antistatic agent for resins according to Claim 7, wherein the antistatic agent is for polyurethane resins or for epoxy resins.

9. (Original) An antistatic resin composition, containing a resin and phosphonium salts represented by the general formula (1):



(wherein R¹, R², and R³ are each a straight-chain or branched alkyl group having 3 to 8 carbon atoms, and R⁴ is a straight-chain or branched alkyl group having 10 to 22 carbon atoms; each alkyl group may have substituted hydroxy group or alkoxy group; R¹, R², and R³ may be the same or different from each another; and X⁻ is a tetrafluoroborate ion or a hexafluorophosphate ion).

- 10. (Original) The antistatic resin composition according to Claim 9, wherein the phosphonium salt is tri-n-butyl-n-hexadecylphosphonium tetrafluoroborate.
- 11. (Original) The antistatic resin composition according to Claim 9, wherein the phosphonium salt is tri-n-butyl-n-hexadecylphosphonium hexafluorophosphate.
- 12. (Currently Amended) The antistatic resin composition according to any of-Claims 9 to 11 Claim 9, wherein the amount of the phosphonium salt compounded is 0.01 to 50 weight parts per 100 weight parts resin.
- 13. (Currently Amended) The antistatic resin composition according to any of Claims 9 to 12Claim 9, wherein the resin is a thermoplastic resin.
- 14. (Original) The antistatic resin composition according to Claim 13, wherein the thermoplastic resin is a polyamide or a polyester.
- 15. (Currently Amended) The antistatic resin composition according to any of Claims 9 to 12Claim 9, wherein the resin is a thermoset resin.

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16. (Original) The antistatic resin composition according to Claim 15, wherein the thermoset resin is polyurethane resin or epoxy resin.

- 17. (Currently Amended) The antistatic resin composition according to any of Claims 9 to 16Claim 9, wherein carbon material is further contained.
- 18. (Original) The antistatic resin composition according to Claim 17, wherein the carbon nanotubes are contained as the carbon material.
- 19. (Currently Amended) An antistatic resin molded product, wherein the antistatic resin composition of any of Claims 9 to 18 Claim 9 is molded.